

<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  (Use several sheets if necessary)		Attorney Docket No.: <b>8038-1074</b>		<b>10483077</b> Application No.: NEW NATIONAL PHASE		
		Applicant: <b>Takashi ABE et al.</b>				
		Filing Date: <b>June 15, 2006</b>		Group Art Unit:		
<b>U.S. PATENT DOCUMENTS</b>						
Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (if appropriate)
<b>FOREIGN PATENT DOCUMENTS</b>						
Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation
						Yes
/ZV/	2004-352629	12/16/2004	JAPAN			
	11-130669	5/18/1999	JAPAN			
	2002-510317	4/2/2002	JAPAN			
	93/06834	4/15/1993	WO			
	08-502039	3/5/1996	JAPAN			
	11-302164	11/2/1999	JAPAN			
	11-302163	11/2/1999	JAPAN			
	09-040554	2/10/1997	JAPAN			
	08-198748	08/06/1996	JAPAN			
	2003-102451	04/08/2003	JAPAN			
	2000-072669	03/07/2000	JAPAN			
	2003-119127	04/23/2003	JAPAN			
	2003-169630	06/17/2003	JAPAN			
	2001-348334	12/18/2001	JAPAN			
	05-049444	03/02/1993	JAPAN			
	05-339148	12/21/1993	JAPAN			
▼	63-054320	03/08/1988	JAPAN			
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>						
EXAMINER:  /Zohreh Vakili/ (11/16/2007)		DATE CONSIDERED  /Zohreh Vakili/ (11/16/2007)				
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.						

\* English language abstract provided for the Examiner's convenience

Idw